What Is Claimed Is:

l.	A	circuit	com	pris	ing:
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- a MOS transistor having a cap layer comprised of a high dielectric constant material.
- 2. The circuit of Claim 1 wherein said high dielectric constant material is hafnium silicon oxynitride.
 - 3. The circuit of Claim 1 wherein said MOS transistor is a PMOS transistor.
 - 4. The circuit of Claim 1 wherein said MOS transistor is a NMOS transistor.
 - 5. A MOS transistor comprising:
 - a cap layer comprised of a high dielectric constant material.
- 6. The MOS transistor of Claim 5 wherein said high dielectric constant material is hafnium silicon oxynitride.
 - 7. The MOS transistor of Claim 5 wherein said MOS transistor is a NMOS transistor.
 - 8. The MOS transistor of Claim 5 wherein said MOS transistor is a PMOS transistor.
 - 9. A PMOS transistor comprising:
 - a cap layer comprised of a high dielectric constant material.

- 10. The PMOS transistor of Claim 9 wherein said high dielectric constant material is hafnium silicon oxynitride.
 - 11. A PMOS transistor comprising:
 - a cap layer comprised of hafnium silicon oxynitride.